

Fig 1. Vapor pressure curves comparison of **RosiTa**TM, TBTEMT, and PET [Ta₂(OEt)₁₀].

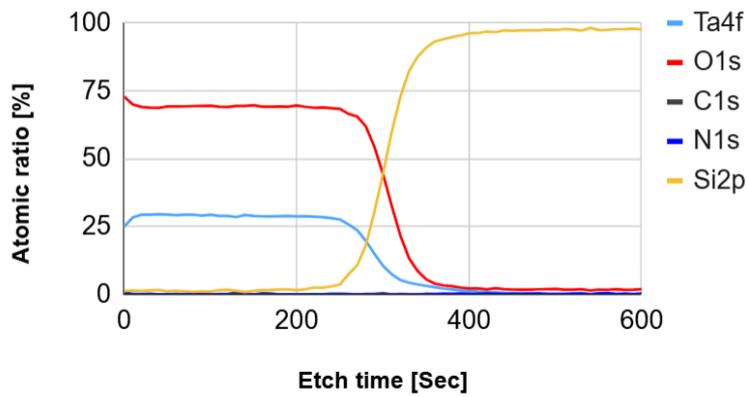


Fig. 2 XPS depth profile of ALD Ta₂O₅ at 300 °C using **RosiTa**TM and O₃.

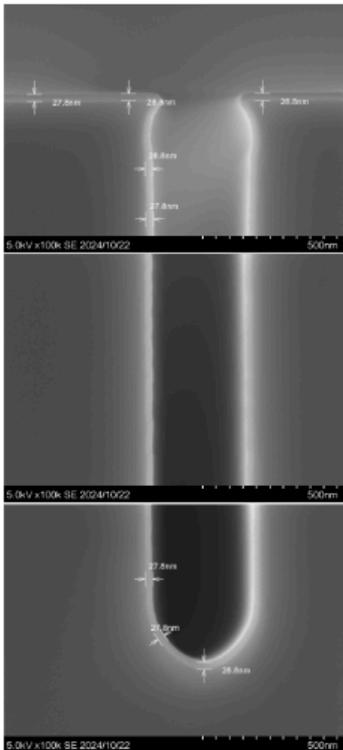


Fig 3. SEM analysis of Ta₂O₅ film (300 °C, AR=18, 600 cycles) using **RosiTa**TM and O₃.